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RESPONSE UNDER 37 C.F.R. 1.116 EXPEDITED PROCEDURE--EXAMINING GROUP 1762

Attorney's Docket No. 5308/157IP2

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Das et al.

Serial No.: 10/045,542

Filed: October 26, 2001

Confirmation No.: 3570 Group Art Unit: 1762 Examiner: Bret P. Chen

METHOD OF FABRICATING AN OXIDE LAYER ON A SILICON CARBIDE

LAYER UTILIZING AN ANNEAL IN A HYDROGEN ENVIRONMENT

Date: August 16, 2005

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

AMENDMENT AFTER FINAL

Sir:

Applicants provide the present Amendment to address the issues raised in the Final Official Action mailed May 18, 2005 and subsequent Advisory Action of August 5, 2005.

It is not believed that an extension of time and/or additional fee(s)-including fees for net addition of claims-are required, beyond those that may otherwise be provided for in documents accompanying this paper. In the event, however, that an extension of time is necessary to allow consideration of this paper, such an extension is hereby petitioned under 37 C.F.R. §1.136(a). Any additional fees believed to be due in connection with this paper may be charged to our Deposit Account No. 50-0220.

Amendments to the Claims begin on page 2 of this paper.

Remarks begin on page 6 of this paper.

AF